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Supporting Information

Pressure-induced Changes in Crystal Structure and Electrical Conductivity of GeV₄S₈

Yuejian Wang^{*}, Zhiwei Shen[#], Dongzhou Zhang[¶], Lin Wang[#], Vladimir Tsurkan^{§†}, Lilian Prodan^{§†}, Alois Loidl[§], Bishal B. Dumre[&], Sanjay V. Khare[&]

*Physics Department, Oakland University, Rochester, Michigan 48309, United States
#Center for High-Pressure Science (CHiPS), State Key Laboratory of Metastable Materials Science and Technology, Yanshan University, Qinhuangdao, Hebei 066004, China
*Partnership for Extreme Crystallography, University of Hawaii at Manoa, Honolulu, Hawaii 96822, United States
*Experimental Physics V, Center for Electronic Correlations and Magnetism, University of Augsburg 86135, Germany
*Institute of Applied Physics, Moldova State University, MD-2028 Chisinau, Republic of Moldova
*Department of Physics and Astronomy, and Wright Center for Photovoltaics Innovation and Commercialization (PVIC), University of Toledo, Toledo, Ohio 43606, United States

*E-mail: <u>ywang235@oakland.edu</u>

More by <u>Yuejian Wang</u>

http://orcid.org/0000-0001-6663-5912

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Table S1: Crystallographic data of the starting cubic and high-pressure orthorhombic phases of GeV_4S_8

Space group		
Pressure	ambient	59.8 GPa
a (Å)	9.6576	6.3577
b (Å)		6.7687
c (Å)		7.2481
V (Å ³)	900.76	311.910
Atomic	Ga(1): 4a [0, 0, 0]	Ga(1):2a [0, 0, 0]
coordinates	V(1):16e [0.60576, 0.60576, 0.60576]	V(1):4d [0, 0.21190, 0.64538]
	S(1):16e [0.37049, 0.37049, 0.37049]	V(2):4c [0.20805, 0, 0.44341]
	S(2):16e [0.86100, 0.86100, 0.86100]	S(1):4d [0, 0.75879, 0.36694]
		S(11):4c [0.26053, 0, 0.75607]
		S(2):4d [0, 0.70001, 0.95447]
		S(21):4c [0.29172, 0, 0.14977]

Table S2: Raman Band, band frequency, ω_o , at ambient condition, and Grneisen parameter,

 γ , of the cubic phase of GeV₄S₈. The uncertainties are enclosed in the parenthesis.

Region	Band	$\omega_o (cm^{-1})$	$\frac{d\omega}{dP} \left(\frac{cm^{-1}}{GPa}\right)$	γ
Ι	A_1	279.1(3.3)	5.4(0.5)	2.05(0.28)
	E	414.2(1.7)	4.4(0.2)	1.12(0.11)
	E	370.7(3.2)	7.1(0.5)	2.01(0.23)
	B_1	346.2(1.5)	4.4(0.2)	1.33(0.12)
II	A ₁	318.5(1.7)	2.1(0.1)	0.68(0.05)
	E	440.2(1.6)	2.2(0.1)	0.53(0.03)
	E	418.0(4.1)	3.6(0.1)	0.90(0.08)
	B_1	370.7(1.7)	2.4(0.1)	0.69(0.04)

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Figure S1: Electronic Band Structure for GeV₄S₈ calculated using GGA in primitive unit cell. The solid line represents spin up whereas dotted lines represent spin down.

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Figure S2. Electronic Local Density of States (LDOS) for GeV₄S₈ calculated using HSE06 in primitive unit cell at different pressures.